

# Tatsuru Shirafuji

## List of Publications by Year in descending order

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Version: 2024-02-01

39  
papers

377  
citations

933447

10  
h-index

794594

19  
g-index

39  
all docs

39  
docs citations

39  
times ranked

281  
citing authors

#	ARTICLE	IF	CITATIONS
1	Observation of self-organized filaments in a dielectric barrier discharge of Ar gas. Applied Physics Letters, 2003, 83, 2309-2311.	3.3	107
2	Plasma Copolymerization of Tetrafluoroethylene/Hexamethyldisiloxane and In Situ Fourier Transform Infrared Spectroscopy of Its Gas Phase. Japanese Journal of Applied Physics, 1999, 38, 4520-4526.	1.5	39
3	Underwater microdischarge in arranged microbubbles produced by electrolysis in electrolyte solution using fabric-type electrode. Applied Physics Letters, 2008, 93, .	3.3	36
4	Measurement and Calculation of $\text{SiH}_2$ Radical Density in $\text{SiH}_4$ and $\text{Si}_2\text{H}_6$ Plasma for the Deposition of Hydrogenated Amorphous Silicon Thin Films. Japanese Journal of Applied Physics, 1995, 34, 4239-4246.	1.5	17
5	Solution Plasma Surface Modification for Nanocarbon-Composite Materials. Nippon Kinzoku Gakkaishi/Journal of the Japan Institute of Metals, 2009, 73, 938-942.	0.4	16
6	Generation of Three-Dimensionally Integrated Micro Solution Plasmas and Its Application to Decomposition of Organic Contaminants in Water. Journal of Photopolymer Science and Technology = [Fotoporima Konwakai Shi], 2013, 26, 507-511.	0.3	15
7	In Situ Ellipsometric Monitoring of the Growth of Polycrystalline Silicon Thin Films by RF Plasma Chemical Vapor Deposition. Japanese Journal of Applied Physics, 1994, 33, 4191-4194.	1.5	13
8	Plasma Copolymerization of $\text{C}_6\text{F}_6/\text{C}_5\text{F}_8$ for Application of Low-Dielectric-Constant Fluorinated Amorphous Carbon Films and Its Gas-Phase Diagnostics Using In Situ Fourier Transform Infrared Spectroscopy. Japanese Journal of Applied Physics, 2004, 43, 2697-2703.	1.5	13
9	Tailoring the Chemistry of Plasma-Activated Water Using a DC-Pulse-Driven Non-Thermal Atmospheric-Pressure Helium Plasma Jet. Plasma, 2019, 2, 127-137.	1.8	13
10	Dry Etching of $\text{SiO}_2$ Thin Films with Perfluoropropenoxide $\text{C}_2\text{F}_5\text{O}_2$ and Perfluoropropene $\text{C}_3\text{F}_6$ Plasmas. Japanese Journal of Applied Physics, 2002, 41, 6287-6290.	1.5	10
11	Diamond Nucleation on Singlecrystalline 6H-SiC Substrates by Bias-Enhanced Nucleation in Hot Filament Chemical Vapor Deposition. Japanese Journal of Applied Physics, 1997, 36, 6295-6299.	1.5	9
12	Rethinking surface reactions in nanoscale dry processes toward atomic precision and beyond: a physics and chemistry perspective. Japanese Journal of Applied Physics, 2019, 58, SE0801.	1.5	9
13	Generation of Plasmas in Multiphase Medium. Transactions of the Materials Research Society of Japan, 2010, 35, 81-83.	0.2	9
14	Numerical Investigation of Electric Field in Gas Bubbles Surrounded with Conductive Liquid and Dielectric Material. Transactions of the Materials Research Society of Japan, 2013, 38, 321-323.	0.2	9
15	Three-Dimensionally Integrated Micro-solution Plasma: Numerical Feasibility Study and Practical Applications. Plasma Chemistry and Plasma Processing, 2014, 34, 523-534.	2.4	8
16	In vivo study on the healing of bone defect treated with non-thermal atmospheric pressure gas discharge plasma. PLoS ONE, 2021, 16, e0255861.	2.5	8
17	Total reflection X-ray fluorescence analysis with a glass substrate treated with a He atmospheric pressure plasma jet. Journal of Analytical Atomic Spectrometry, 2021, 36, 1873-1878.	3.0	7
18	Construction and Performance of a Fourier-Transform Infrared Phase-Modulated Ellipsometer for In-Process Surface Diagnostics. Japanese Journal of Applied Physics, 1996, 35, 3652-3657.	1.5	6



#	ARTICLE	IF	CITATIONS
37	The Japan Society of Vacuum and Surface Science Accepts Plasmas in Atmospheric Pressure and in Liquid. <i>Vacuum and Surface Science</i> , 2019, 62, 543-543.	0.1	0
38	Autumn Joint Lecture of Kansai Branches. <i>Vacuum and Surface Science</i> , 2019, 62, 735-735.	0.1	0
39	Recent Progress in Electrical Discharges, Plasma, and Pulsed Power Technologies. <i>IEEJ Transactions on Fundamentals and Materials</i> , 2020, 140, 10-11.	0.2	0